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PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Docket No: Q62053

Nobuyoshi YAGI, et al.

Appln. No.: 09/769,376

Confirmation No.: 5759

Filed: January 26, 2001



Group Art Unit: 1774

Examiner: Kimberly T. Nguyen

For: RESIN SUBSTRATE FOR OPTICAL USE

AMENDMENT UNDER 37 C.F.R. § 1.111

Commissioner for Patents
Washington, D.C. 20231

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JUL 16 2002

TC 1700

Sir:

This Amendment is submitted in response to the Office Action dated April 11, 2002 in the above-identified application. Kindly amend this application as follows:

IN THE CLAIMS:

Please enter the following amended claims:

- Sub B1
- AI
1. (Amended) A resin substrate for optical use which comprises a multilayer structure having a surface roughness Ra of 0.8 nm or lower on at least one side and having an average thickness of from 100 to 800 μm .
 2. (Amended) The resin substrate for optical use of claim 1, wherein the multilayer structure comprises a layer of a cured epoxy resin as a base layer.
 3. (Amended) The resin substrate for optical use of claim 2, wherein the multilayer structure further comprises a transparent hard coat layer having a thickness of 0.1 μm

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or larger as a surface layer and a poly(vinyl alcohol)-based gas barrier layer as an intermediate layer between the hard coat layer and the base layer.
